

Fabrication of ^{197}Au target using high vacuum evaporator facility at IUAC, New Delhi

Nishant Shukla^{1,*}, S.R. Abhilash² and D.Kabiraj²

¹Centre for Applied Physics, Central University Of Jharkhand, Ranchi-835 205, India

²Inter University Accelerator Centre, Aruna Asaf Ali Marg, New Delhi - 110 067, India

* email:shukla.coolnishu@gmail.com

Introduction

With the availability of heavy ion accelerators it has been possible to study nuclear structure and nuclear reaction mechanism of heavy ion collisions. To understand the nuclear reaction mechanism in heavy ion collision, uniform and high Z target is required. The high vacuum evaporator facility of IUAC was used in the fabrication of an enriched ^{197}Au in the form of shots target on substrate of glass slides and soap solution as parting agent. Accurate determination of thin target thickness is quite important in nuclear physics experiment. In principle there are many methods for measuring foil thickness. Basically Alpha energy loss method, Quartz crystal method and step height techniques had been used for a comparative study of the differences produced.

Details of High Vacuum Evaporation Chamber

The evaporation of the shot of ^{197}Au target material on substrate of glass slides with soap solution as parting agent was carried out in High Vacuum Evaporator Chamber in the target laboratory of Inter University Accelerator Centre (IUAC), New Delhi, India. Vacuum of the chamber during the evaporation of ^{197}Au material on glass substrate with soap solution as parting agent was achieved and sustained of the order 10^{-6} mbar using diffusion pump. The target material was evaporated using the method of resistance evaporation technique. The evaporator was equipped with a quartz crystal thickness monitor, which gives the thickness of deposited material as well as the rate of evaporation on the crystal.

Procedure of Fabrication

In the first step, soap solutions was applied on the glass substrates. The slides with a layer of the soap solution was left to dry after which the layer of it was made even by polishing. The slides were mounted on the slide holder of the chamber. Several attempts were made in the deposition of ^{197}Au material on the glass substrate with soap solution as the parting agent to identify the right position of the substrate from the boat so that we may reach on the required thickness. After getting the required thickness using fewer amounts of the natural Gold shots, the distance between the substrate and boat was noted. The suitable distance of Dimple boat of Tungsten to substrate was found to be 15 cm. After completing the testing the setting of all parameters and adjustment of vacuum chamber for the ^{197}Au material deposition has been done. The distance between Dimple boat and substrate was fixed at 15 cm. The Quartz Crystal monitor has been fixed on a distance 16 cm. ^{197}Au shot of density 19.3 and 6.35 mm semi-spherical shot has been put inside the dimple boat. Then, we achieved the vacuum inside the chamber $\sim 10^{-7}$ mbar using diffusion pump. The diffusion pump was started at the current of approx. 170 A in the resistive heating process. The deposition rate was sustained 0.1 nm/ sec for the uniform deposition of ^{197}Au . Deposition was stopped on reaching the required thickness of ^{197}Au material on glass substrate with soap solution as the parting agent. The thickness of the deposited ^{197}Au material was also verified by α -transmission method using ^{241}Am source. We have prepared 6 thin enriched ^{197}Au targets on glass substrate with soap solution as parting agent of thickness ranging from $\approx 300 - 400 \mu\text{g}/\text{cm}^2$ using the

vacuum evaporation technique from the very less amount of material.



Fig. 1: Substrate after the deposition of ^{197}Au on glass substrate with soap solution as parting agent.

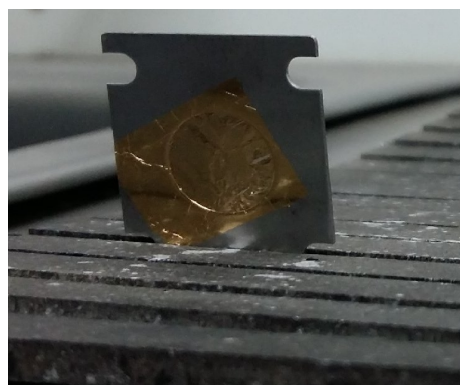


Fig. 3: Prepared targets of ^{197}Au .

a.



b.



Fig. 2 (a): High Vacuum Evaporation setup for the evaporation of target material with Dimple boat.

(b) Dimple boat of Tungsten used for evaporation.

Acknowledgments

Authors are thankful to the Director, IUAC, New Delhi for providing necessary facilities for fabrication of target. One of the author Nishant Shukla gratefully acknowledge to the Head, Centre for Applied Physics (CAP), Central University of Jharkhand, Ranchi for their encouragement during this work. Nishant Shukla is also thankful to Dr. Dharmendra Singh, CAP, CUJ, Ranchi for their motivation and discussion during the present work. I am also very much thankful to Dr. P. Sugathan, IUAC, New Delhi for their help and support during this work.

References:

- (1) W.R.Leo - Techniques for Nuclear and Particle Physics Experiments, Second revised edition, Springer-Verlag (1993)
- (2) G.F.Knoll- Radiation Detection and Measurement, Fourth edition, John Wiley & Sons Inc.
- (3) Bernard L.Cohen - Concepts of Nuclear Physics, Mc Graw-Hill (1989)